

05/29/2008

**RESPONSE UNDER 37 C.F.R.  
§1.116 EXPEDITED PROCEDURE  
EXAMINING GROUP 1792**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**Applicant(s):** Kwang Choe et al.

**Examiner:** Padgett, Marianne L.

**Serial No.:** 10/674,648

**Docket No:** YOR920030294US1(16817)

**Filed:** September 30, 2003

**Group Art Unit:** 1792

**Title:** SOI BY OXIDATION OF  
POROUS SILICON

**Date:** May 14, 2008

**Confirmation No.:** 4794

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

*A.L.H. 6/10/08  
ANE-I  
Entered per REC  
dated 6/4/08*

**RESPONSE UNDER 37 C.F.R. §1.116**

Sir:

In response to the Final Rejection dated March 14, 2008, please enter the following remarks and amendments as a matter of record in the above-identified application.

**Amendments to the Claims** are reflected in the listing of claims, which begin on page 2 of this paper.

**Remarks** begin on page 6 of this paper.

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**CERTIFICATE OF ELECTRONIC FILING**

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on May 14, 2008.

Dated: May 14, 2008

  
Harry A. Hild Jr.